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IN THE CLAIMS

The following will replace all prior versions, and listings, of the claims in this application:

- 1. (Canceled)
- 2. (Canceled)
- 3. (Currently Amended) The optical monitoring system of claim 1, An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator; and
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator:
- wherein said first fiber optic collimator comprises a two-fiber ferule that is coupled to said first fiber and said second fiber, wherein said second fiber transmits reflected light.
- 4. (Currently Amended) The optical monitoring system of claim 1, further comprising: An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator; and
 - a second fiber optic collimator coupled to said second fiber,
 - wherein said second fiber transmits transmitted light.

- 5. (Currently Amended) The optical monitoring system of claim 1, further comprising: An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator; and
 - a second fiber optic collimator coupled to said second fiber,
 - wherein said second fiber transmits reflected light.
- 6. (Currently Amended) The optical monitoring system of claim 1, An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator; and
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator:
 - wherein said first fiber optic collimator comprises a GRIN lens.
- 7. (Previously Presented) The optical monitoring system of claim 6, wherein said first fiber optic collimator comprises a tap optical filter and an alignment glass rod.
- 8. (Currently Amended) The optical monitoring system of claim 1, An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising;
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator, and
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator.
- wherein the substrate comprises a monitored area that is monitored by collimated light from said first fiber optic collimator.

- 9. (Currently Amended) The optical monitoring system of claim 1, further comprising: An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber,
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator; and
 - a strobe signal generator.
- 10. (Currently Amended) The optical monitoring system of claim 2, further comprising: An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator;
- a substrate holder configured to hold the substrate; a first shutter that prevents incoming deposition material from contacting at least a first portion of the substrate; and
- a second shutter that prevents incoming deposition material from contacting at least a second portion of the substrate.
- 11. (Currently Amended) The optical monitoring system of claim 2, An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber;
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator,
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator:
 - a substrate holder configured to hold the substrate; and

a first shutter that prevents incoming deposition material from contacting at least a first portion of the substrate;

wherein said first shutter is closed when a predetermined optical thickness on the substrate is reached.

- 12. (Previously Considered) The optical monitoring system of claim 11, wherein a determination is made that a predetermined optical thickness on the substrate is reached using an iterative process that includes a calculation of a predicted optical thickness.
- 13. (Currently Amended) The optical monitoring system of claim—1, An optical monitoring system for monitoring thin film deposition on a substrate, said system comprising:
 - a support configured to be attached on an inside of a deposition chamber,
 - a first fiber optic collimator supported by said support;
 - a first fiber for incoming light coupled to said first fiber optic collimator; and
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator;
- wherein said first fiber and said second fiber are comprised of a single fiber, and further comprising a beam splitter coupled to said single fiber.
- 14. (Previously Presented) A thin film substrate deposition device comprising:
 - a deposition chamber;
 - a support coupled to said deposition chamber;
 - a first fiber optic collimator coupled to said support;
 - a first fiber for incoming light coupled to said first collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator;
 - a substrate holder coupled to said deposition chamber; and
- a first shutter coupled to said deposition chamber and movable from an open position to a closed position that prevents incoming deposition material from contacting at least a first portion of the substrate.

- 15. (Original) The thin film substrate deposition device of claim 14, wherein said first fiber optic collimator comprises a two-fiber ferule that is coupled to said first fiber and said second fiber, wherein said second fiber transmits reflected light.
- 16. (Previously Presented) The thin film substrate deposition device of claim 14, further comprising:
- a second fiber optic collimator coupled to said support, wherein said second fiber transmits transmitted light.
- 17. (Previously Presented) The thin film substrate deposition device of claim 14, further comprising:
- a second fiber optic collimator coupled to said support, wherein said second fiber transmits reflected light.
- 18. (Original) The thin film substrate deposition device of claim 14, wherein said first fiber optic collimator comprises a GRIN lens.
- 19. (Original) The thin film substrate deposition device of claim 18, wherein said first fiber optic collimator comprises a tap optical filter and an alignment glass rod.
- 20. (Original) The thin film substrate deposition device of claim 14, wherein the substrate comprises a monitored area that is monitored by collimated light from said first fiber optic collimator.
- 21. (Previously Presented) The thin film substrate deposition device of claim 14, further comprising:
 - a strobe signal generator.
- 22. (Original) The thin film substrate deposition device of claim 14, further comprising:

a second shutter that prevents incoming deposition material from contacting at least a second portion of the substrate.

- 23. (Previously Presented) The thin film substrate deposition device of claim 14, wherein said first shutter is closed when a predetermined optical thickness on the substrate is reached.
- 24. (Previously Presented) The thin film substrate deposition device of claim 23, wherein a determination is made that a predetermined optical thickness on the substrate is reached using an iterative process that includes a calculation of a predicted optical thickness
- 25. (Original) The thin film substrate deposition device of claim 14, wherein said first fiber and said second fiber are comprised of a single fiber, and further comprising a beam splitter coupled to said single fiber.

26-32. (Canceled)

- 33. (Previously Presented) A deposition chamber having an optical monitoring system therein suitable for monitoring thin film deposition on a substrate, said optical monitoring system comprising:
 - a first fiber for incoming light coupled to a first fiber optic collimator;
 - a second fiber for outgoing light optically coupled to said first fiber optic collimator; and
 - a first shutter movable between:

an open position in which said first shutter permits incoming deposition material to contact at least a first portion of a substrate, and

- a closed position in which said first shutter prevents incoming deposition material from contacting said at least a first portion of a substrate.
- 34. (Previously Presented) The deposition chamber according to claim 33, further comprising:

a second shutter configured, when in the closed position, to prevent incoming deposition material from contacting at least a second portion of a substrate.

- 35. (Previously Presented) The deposition chamber according to claim 34, wherein the first and second portions belong to separate substrates.
- 36. (Previously Presented) The deposition chamber according to claim 34, wherein the first and second shutters are autonomously controlled.
- 37. (Previously Presented) The deposition chamber according to claim 36, wherein the first and second shutters are connected to a substrate holder within the deposition chamber.
- 38. (Previously Presented) The deposition chamber according to claim 37, wherein the first and second shutters are rotated between the open and closed positions by a driver fixed on the substrate holder.
- 39. (Previously Presented) The deposition chamber according to claim 33, wherein said first fiber optic collimator comprises a two-fiber ferule, an alignment glass rod, a tap optical filter and a GRIN lens.
- 40. (Previously Presented) The deposition chamber according to claim 39, wherein said two-fiber ferule is coupled to said first and second fibers, and wherein said second fiber transmits reflected light.
- 41. (Previously Presented) The deposition chamber according to claim 33, further comprising: a second fiber optic collimator coupled to said second fiber.
- 42. (Previously Presented) The deposition chamber according to claim 41, wherein each of said first and second fiber optic collimators comprises a single-fiber ferule and a GRIN lens.

- 43. (Previously Presented) The deposition chamber according to claim 41, wherein said second fiber transmits reflected light.
- 44. (Previously Presented) The deposition chamber according to claim 41, wherein said second fiber transmits transmitted light.
- 45. (Previously Presented) The deposition chamber according to claim 33, wherein said first fiber and said second fiber are comprised of a single fiber, and further comprising a beam splitter coupled to said single fiber.
- 46. (Previously Presented) The deposition chamber according to claim 33, wherein said first fiber optic collimator comprises a GRIN lens.
- 47. (Previously Presented) The deposition chamber according to claim 33, wherein said first fiber optic collimator comprises a tap optical filter and an alignment glass rod.
- 48. (Previously Presented) The deposition chamber according to claim 33, further comprising: a strobe signal generator.
- 49. (Previously Presented) The deposition chamber according to claim 33, wherein said first shutter is closed when a predetermined optical thickness on the substrate is reached.
- 50. (Previously Presented) The deposition chamber according to claim 33, wherein a determination is made that a predetermined optical thickness on the substrate is reached using an iterative process that includes a calculation of a predicted optical thickness.
- 51. (Previously Presented) The deposition chamber according to claim 33, further comprising a substrate holder configured to rotate the substrate.

- 52. (Previously Presented) The deposition chamber according to claim 51, wherein the substrate undergoes rotation around more than one axis.
- 53. (Previously Presented) The deposition chamber according to claim 52, wherein the substrate undergoes planetary rotation.
- 54. (Previously Presented) The deposition chamber according to claim 33, wherein the substrate is monitored from its back side.
- 55. (Previously Presented) The deposition chamber according to claim 33, wherein the first fiber optic collimator is attached to the substrate.
- 56. (Previously Presented) The deposition chamber according to claim 55, wherein the first fiber optic collimator is attached to the substrate by glue.
- 57. (Previously Presented) The deposition chamber according to claim 33, wherein the substrate is provided with a strobe mark on a backside thereof for optical monitoring.
- 58. (Previously Presented) The thin film substrate deposition device of claim 14, further comprising a substrate holder configured to rotate the substrate.
- 59. (Previously Presented) The thin film substrate deposition device of claim 58, wherein the substrate is rotated around more than one axis.
- 60. (Previously Presented) The thin film substrate deposition device of claim 59, wherein the substrate undergoes planetary rotation.

- 61. (Previously Presented) The thin film substrate deposition device of claim 14, wherein the substrate is monitored from its back side.
- 62. (Previously Presented) The thin film substrate deposition device of claim 14, wherein the first fiber optics collimator is attached to the substrate.
- 63. (Previously Presented) The thin film substrate deposition device of claim 62, wherein the first fiber optics collimator is attached to the substrate by glue.
- 64. (Previously Presented) The deposition chamber according to claim 14, wherein the substrate is provided with a strobe mark on a backside thereof for optical monitoring.
- 65. (Previously Presented) The optical monitoring system of claim 13, wherein the first fiber is configured to both transmit and reflect light.
- 66. (Previously Presented) The optical monitoring system of claim 13, wherein the beam splitter is configured to separate a reflected signal from an incoming signal.
- 67. (Previously Presented) The optical monitoring system of claim 13, wherein the beam splitter is an optical circulator.
- 68. (Canceled)
- 69. (Canceled)